## Adsorption-induced active vanadium species facilitate excellent performance in low-temperature catalytic NO<sub>x</sub> abatement

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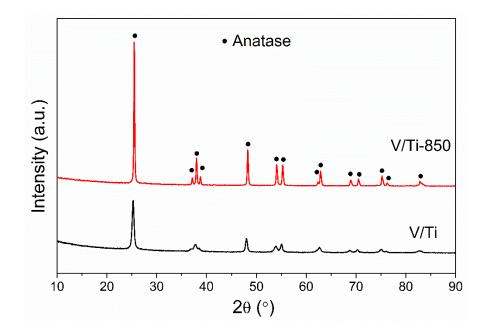


Fig. S1 XRD profiles of V/Ti and V/Ti-850.

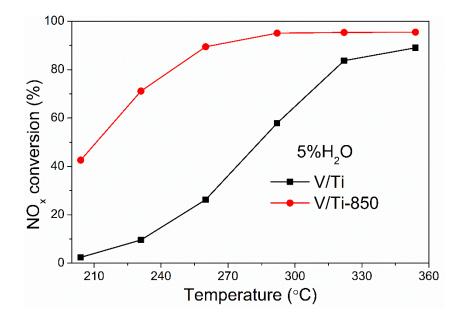


Fig. S2 NH<sub>3</sub>-SCR activity over V/Ti and V/Ti-850 in humid conditions. Reaction conditions: 500 ppm NO, 500 ppm NH<sub>3</sub>, 5 vol.% O<sub>2</sub>, 5 vol.% H<sub>2</sub>O, total gas flow rate of 500 mL min<sup>-1</sup>, space velocity of 100 000 h<sup>-1</sup>, and balanced by N<sub>2</sub> gas.

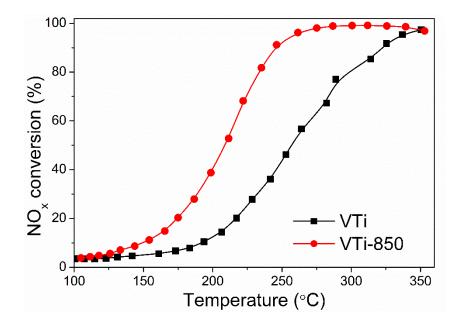


Fig. S3 NO<sub>x</sub> conversion over vanadia-based catalysts while heating from 100 to 350 °C at the rate of 10 °C min<sup>-1</sup>. Reaction conditions: 500 ppm NO, 500 ppm NH<sub>3</sub>, 5 vol.% O<sub>2</sub>, 5 vol.% H<sub>2</sub>O, total gas flow rate of 500 mL min<sup>-1</sup>, space velocity of 100 000  $h^{-1}$ , and balanced by N<sub>2</sub> gas.

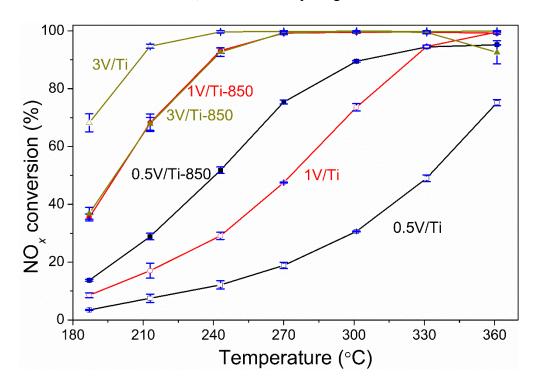


Fig. S4 The NH<sub>3</sub>-SCR activity over vanadia-based catalysts with different vanadia loadings before and after thermal treatment. Reaction conditions: 500 ppm NO, 500 ppm NH<sub>3</sub>, 5 vol.% O<sub>2</sub>, total gas flow rate of 500 mL min<sup>-1</sup>, space velocity of 100 000

h<sup>-1</sup>, and balanced by N<sub>2</sub> gas.

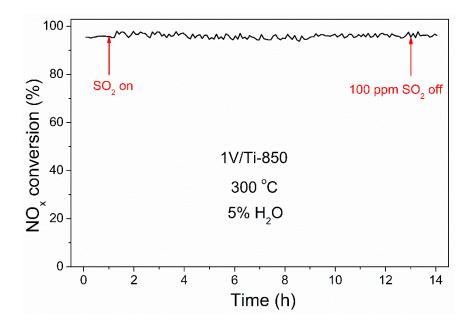


Fig. S5 Effect of SO<sub>2</sub> on NO<sub>x</sub> conversion over the V/Ti-850 catalyst at 300  $^{\circ}$ C. Reaction conditions: 500 ppm NO, 500 ppm NH<sub>3</sub>, 5 vol.% O<sub>2</sub>, 5 vol.% H<sub>2</sub>O, 100 ppm SO<sub>2</sub> (when used), total flow rate of 500 mL min<sup>-1</sup>, space velocity of 100 000 h<sup>-1</sup> and balanced by N<sub>2</sub> gas.

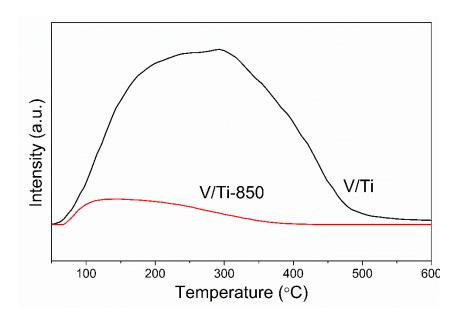


Fig. S6 NH<sub>3</sub>-TPD results of V/Ti and V/Ti-850.

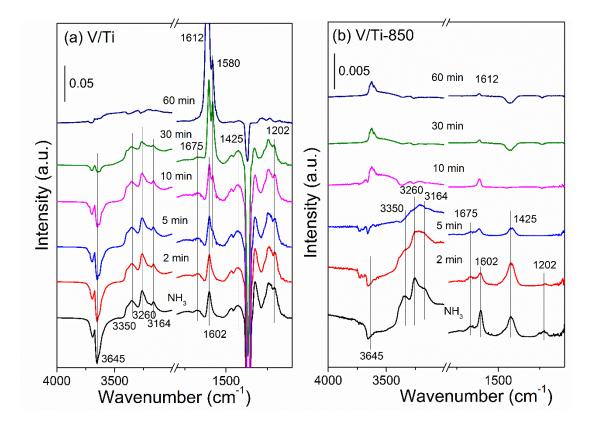


Fig. S7 *In situ* DRIFTS of NO +  $O_2$  reacted with pre-adsorbed NH<sub>3</sub> species at 200 °C on (a) V/Ti, and (b) V/Ti-850.

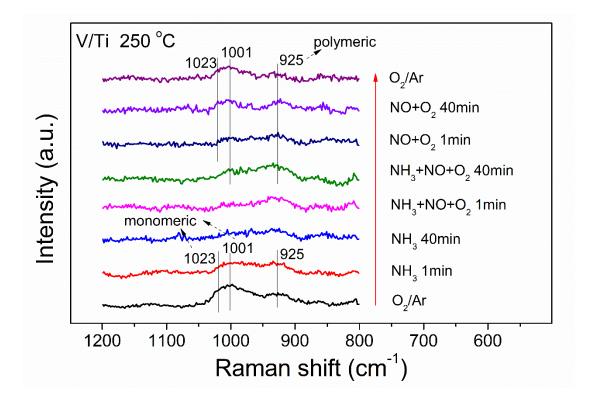


Fig. S8 In situ Raman spectra of V/Ti under different NH<sub>3</sub>-SCR conditions at 250 °C.

## **DFT calculation.**

The formation energy of NH<sub>3</sub>-adsorbed on monomeric, dimeric, and crystalline vanadia loaded on TiO<sub>2</sub> surfaces ( $E_{mono/di/cryst VOx}^{f}$ ) was calculated, which is defined as<sup>1</sup>:

$$E_{mono/di/cryst\,VOx}^{f} = E_{mono/di/cryst\,VOx} - E_{TiO2} - E_{V} - \frac{x}{2}E_{O2}$$

Where  $E_{mon/di/cryst VOx}$ ,  $E_{TiO2}$ ,  $E_V$ , and  $E_{O2}$  are the energies of NH<sub>3</sub>-adsorbed monomeric, dimeric, and crystalline vanadia species loaded on TiO<sub>2</sub>, the TiO<sub>2</sub> surface, bulk vanadium metal, and gas-phase O<sub>2</sub>, respectively. The negative formation energy represents the stabilization of VO<sub>x</sub> species on TiO<sub>2</sub> surfaces. The formation energies are -6.00 eV, -6.88 eV, and -5.86 eV for NH<sub>3</sub>-adsorbed monomeric, dimeric, and crystalline vanadia on TiO<sub>2</sub>, respectively, indicating that the adsorption of NH<sub>3</sub> is beneficial to the formation of polymeric vanadia on TiO<sub>2</sub>.

Table S1 The formation energy (E<sup>f</sup>) of NH<sub>3</sub>-adsorbed monomeric, dimeric, and crystalline vanadia on TiO<sub>2</sub> surfaces.

Species	Monomeric VO <sub>x</sub>	Dimeric VO <sub>x</sub>	Crystalline VO <sub>x</sub>
E <sup>f</sup> (eV)*	-6.00	-6.88	-5.86

\* The formation energies of dimeric, and crystalline vanadia have been normalized to the values of individual  $VO_x$  species.

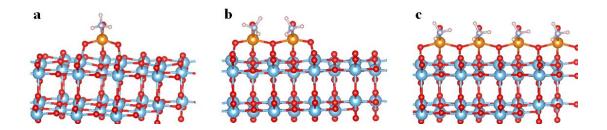


Fig. S9 Optimized geometries of NH<sub>3</sub>-adsorbed on (a) monomeric, (b) dimeric, and
(c) crystalline vanadia loaded on TiO<sub>2</sub> surfaces for formation energy calculations.
Large blue, red, orange, small blue, and white circles denote Ti, O, V, N, and H atoms, respectively.

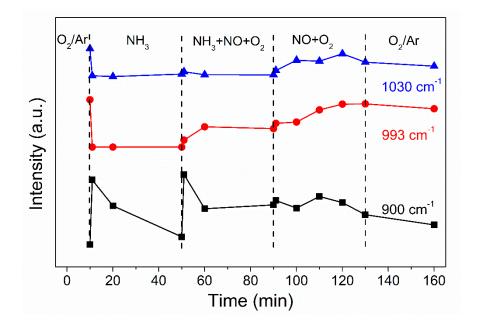


Fig. S10 Plot of the change in integral areas of various Raman peaks of vanadium species under different atmospheres with time.

## References

1. Song, I.; Lee, J.; Lee, G.; Han, J. W.; Kim, D. H., Chemisorption of  $NH_3$  on Monomeric Vanadium Oxide Supported on Anatase TiO<sub>2</sub>: A Combined DRIFT and DFT Study. *J. Phys. Chem. C* **2018**, *122* (29), 16674-16682.